## Effect of linear side-chain length on the photovoltaic performance of benzodithiophene-*alt*-dicarboxylic ester terthiophene polymers

Kangqiao Ma,<sup>a,b</sup> Tao Zhang,<sup>b</sup> Pan Wan,<sup>b</sup> Bowei Xu,<sup>b</sup> Pengxin Zhou<sup>a</sup>\* and Cunbin An<sup>b</sup>\*

<sup>a</sup>College of Chemistry and Chemical Engineering, Northwest Normal University, Lanzhou 730070, China <sup>b</sup>Beijing National Laboratory for Molecular Sciences, State Key Laboratory of Polymer Physics and Chemistry, Institute of Chemistry, Chinese Academy of Sciences, Beijing 100190, China



Figure S1. GPC curves for P3TE-C8 and P3TE-C12 measured at 145 °C.



**Figure S2**. TGA curves for P3TE-C8 and P3TE-C12 measured under a nitrogen atmosphere at a heating rate of 10 °C/min.



Figure S3. The XRD profiles of P3TE-C8 and P3TE-C12.



**Figure S4**. (a) The EQE<sub>EL</sub> of P3TE-C8:ITIC and P3TE-C12:ITIC The band gap of P3TE-C8:IITIC(b) and P3TE-C12:ITIC (c).







Figure S6. The <sup>13</sup>C-NMR spectra of compound 2a in CDCl<sub>3</sub>.



Figure S8. The <sup>13</sup>C-NMR spectra of compound 2b in CDCl<sub>3</sub>.

20 10 0

190 180 170 160 150 140 130 120 110 100 90 80 70 60 50 40 30 fl (ppm)



Figure S9. The <sup>1</sup>H-NMR spectra of compound **3a** in CDCl<sub>3</sub>.



Figure S10. The <sup>13</sup>C-NMR spectra of compound **3a** in CDCl<sub>3</sub>.



Figure S11. The <sup>1</sup>H-NMR spectra of compound **3b** in CDCl<sub>3</sub>.



Figure S12. The <sup>13</sup>C-NMR spectra of compound **3b** in CDCl<sub>3</sub>.



Figure S13. The <sup>1</sup>H-NMR spectra of compound 4a in CDCl<sub>3</sub>.



Figure S14. The <sup>13</sup>C-NMR spectra of compound 4a in CDCl<sub>3</sub>.



Figure S15. The <sup>1</sup>H-NMR spectra of compound 4b in CDCl<sub>3</sub>.



Figure S16. The <sup>13</sup>C-NMR spectra of compound 4b in CDCl<sub>3</sub>.

D:A ratio	$V_{\rm OC}$ (V)	$J_{\rm SC}$ (mA cm <sup>-2</sup> )	FF (%)	PCE (%)
1.5:1	0.797	12.70	45.29	4.58
1:1	0.777	13.52	42.38	4.45
1:1.5	0.769	13.52	40.66	4.23

Table S1. The best photovoltaic parameters of P3TE-C8:ITIC with different D:A weight ratios (w/w).

P3TE-C8:ITIC was dissolved in chlorobenzene solution with a concentration of 10 mg mL<sup>-1</sup>. The solution was heated to 40 °C until total dissolution. The resulting solution was spin-coated onto PEDOT:PSS modified ITO in succession. The thickness (around 90 nm) of film was controlled the spin-coating speed at 1500-2000 r.m.p. Subsequently, the active layer was annealed at 100 °C for 10 min.

 Table S2. The best photovoltaic parameters of P3TE-C8:ITIC with different DIO ratios.

DIO ratio	$V_{\rm OC}$ (V)	$J_{\rm SC}$ (mA cm <sup>-2</sup> )	FF (%)	PCE (%)
0	0.797	12.70	45.29	4.58
0.5%	0.814	12.80	52.48	5.47
1%	0.809	12.24	44.57	4.42
2%	0.815	9.96	39.44	3.20

P3TE-C8:ITIC (1.5:1 w/w) were dissolved in chlorobenzene solution with a concentration of 10 mg mL<sup>-1</sup>. The solution was heated to 40 °C until total dissolution. The DIO was added into above solution. After 30 min, the resulting solution was spin-coated onto PEDOT:PSS modified ITO in succession. The thickness (around 90 nm) of film was controlled the spin-coating speed at 1500 r.m.p. Subsequently, the active layer was annealed at 100 °C for 10 min.

Annealing temperature (°C)	$V_{\rm OC}$ (V)	$J_{\rm SC}$ (mA cm <sup>-2</sup> )	FF (%)	PCE (%)
80	0.827	12.13	49.25	4.94
100	0.814	12.86	52.48	5.47
120	0.825	12.71	50.61	5.31
140	0.828	11.59	52.21	5.30
160	0.829	11.40	51.78	4.89

**Table S3.** The best photovoltaic parameters of P3TE-C8:ITIC with different annealing temperatures.

P3TE-C8:ITIC (1.5:1 w/w)were dissolved in chlorobenzene solution with a concentration of 10 mg mL<sup>-1</sup>. The solution was heated to 40 °C until total dissolution. The 0.5% DIO was added into above solution. After 30 min, the resulting solution was spin-coated onto PEDOT:PSS modified ITO in succession. The thickness (around 90 nm) of film was controlled the spin-coating speed at 1500 r.m.p. Subsequently, the active layer was annealed at 80-160 °C for 10 min.

D:A ratio	$V_{\rm OC}$ (V)	$J_{\rm SC}~({\rm mA~cm^{-2}})$	FF (%)	PCE (%)
1.5:1	0.917	10.15	57.54	5.36
1:1	0.916	12.83	52.06	6.12
1:1.5	0.907	12.46	49.48	5.59

Table S4. The best photovoltaic parameters of P3TE-C12:ITIC with different D:A weight ratios (w/w).

P3TE-C12:ITIC was dissolved in chlorobenzene solution with a concentration of 10 mg mL<sup>-1</sup>. The solution was heated to 40 °C until total dissolution. The resulting solution was spin-coated onto PEDOT:PSS modified ITO in succession. The thickness (around 90 nm) of film was controlled the spin-coating speed at 1500-2000 r.m.p. Subsequently, the active layer was annealed at 100 °C for 10 min.

DIO ratio	$V_{\rm OC}$ (V)	$J_{\rm SC}~({ m mA~cm^{-2}})$	FF (%)	PCE (%)
0	0.916	12.83	52.06	6.12
0.5%	0.904	13.81	55.96	6.99
1%	0.885	11.56	42.86	4.39
2%	0.888	10.14	37.26	3.35

Table S5. The best photovoltaic parameters of P3TE-C12:ITIC with different DIO ratios.

P3TE-C12:ITIC (1:1 w/w) were dissolved in chlorobenzene solution with a concentration of 10 mg mL<sup>-1</sup>. The solution was heated to 40 °C until total dissolution. The DIO was added into above solution. After 30 min, the resulting solution was spin-coated onto PEDOT:PSS modified ITO in succession. The thickness (around 90 nm) of film was controlled the spin-coating speed at 1700 r.m.p. Subsequently, the active layer was annealed at 100 °C for 10 min.

Annealing temperature (°C)	$V_{\rm OC}\left({ m V} ight)$	$J_{ m SC}$ (mA cm <sup>-2</sup> )	FF (%)	PCE (%)
80	0.903	14.25	53.99	6.95
100	0.904	13.81	55.96	6.99
120	0.909	13.50	58.09	7.13
140	0.906	14.20	59.36	7.64
160	0.890	12.57	60.25	6.74

**Table S6.** The best photovoltaic parameters of P3TE-C12:ITIC with different annealing temperatures.

P3TE-C12:ITIC (1:1 w/w)were dissolved in chlorobenzene solution with a concentration of 10 mg mL<sup>-1</sup>. The solution was heated to 40 °C until total dissolution. The 0.5% DIO was added into above solution. After 30 min, the resulting solution was spin-coated onto PEDOT:PSS modified ITO in succession. The thickness (around 90 nm) of film was controlled the spin-coating speed at 1700 r.m.p. Subsequently, the active layer was annealed at 80-160 °C for 10 min.

_	$E_{gap}(eV)$	$qV_{oc}(eV)$	$q\Delta V~(eV)$	$\Delta E_1(\mathrm{eV})$	$\Delta E_2(\mathrm{eV})$	EQE <sub>EL</sub>	$\Delta E_3 (eV)$
P3TE-C8:ITIC	1.66	0.814	0.846	0.276	0.207	7.97E-7	0.363
P3TE-C12:ITIC	1.66	0.906	0.754	0.276	0.141	2.18E-6	0.337

**Table S7.** The detailed energy losses of P3TE-C8:ITIC and P3TE-C12:ITIC-based devices.